

Forward Bias

EE221

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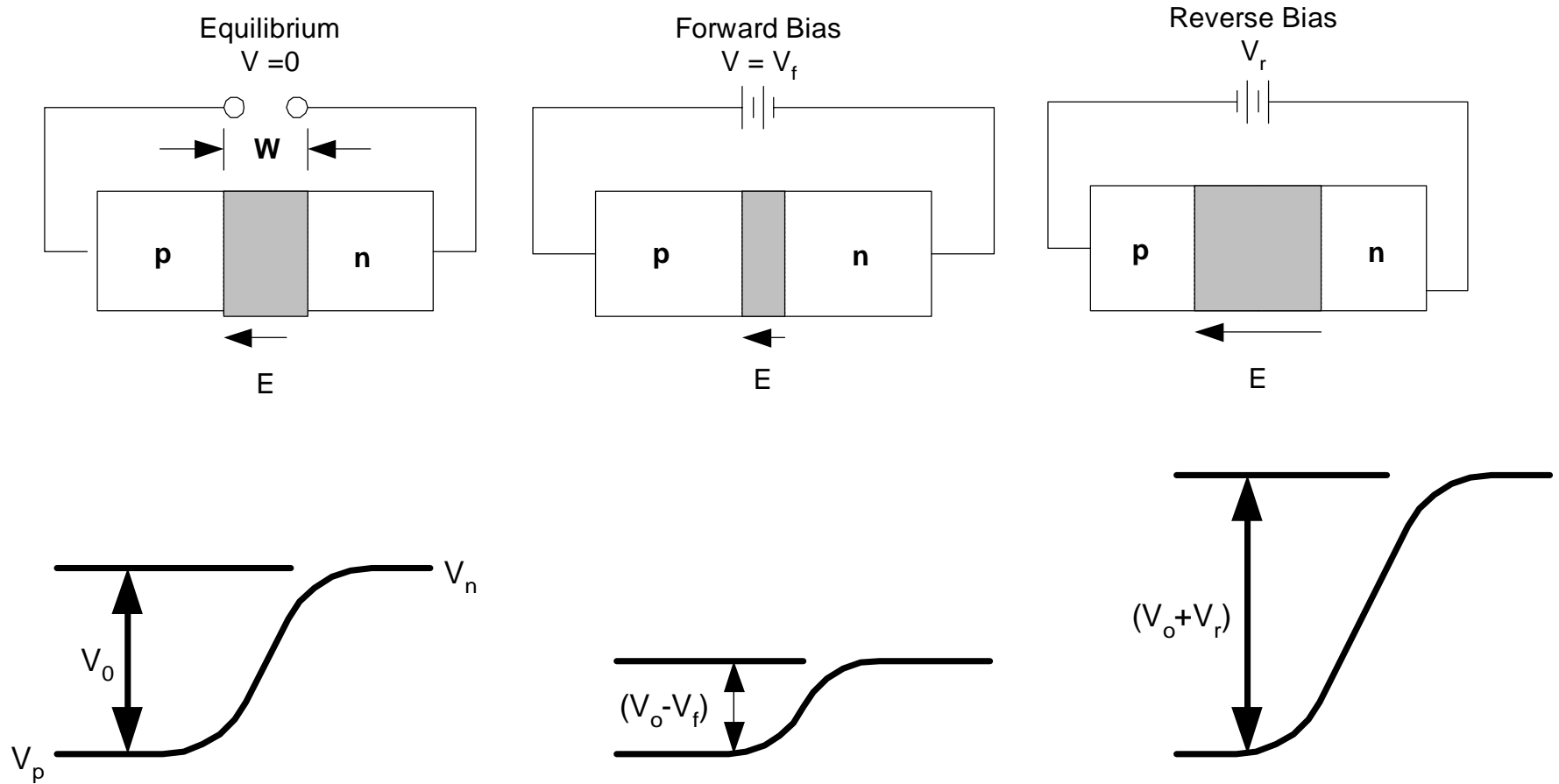
Non-equilibrium conditions in a pn junction

- Equilibrium, forward bias, reverse bias
- Carrier injection
- Calculating junction current
- Minority and majority currents
- Diode equation example

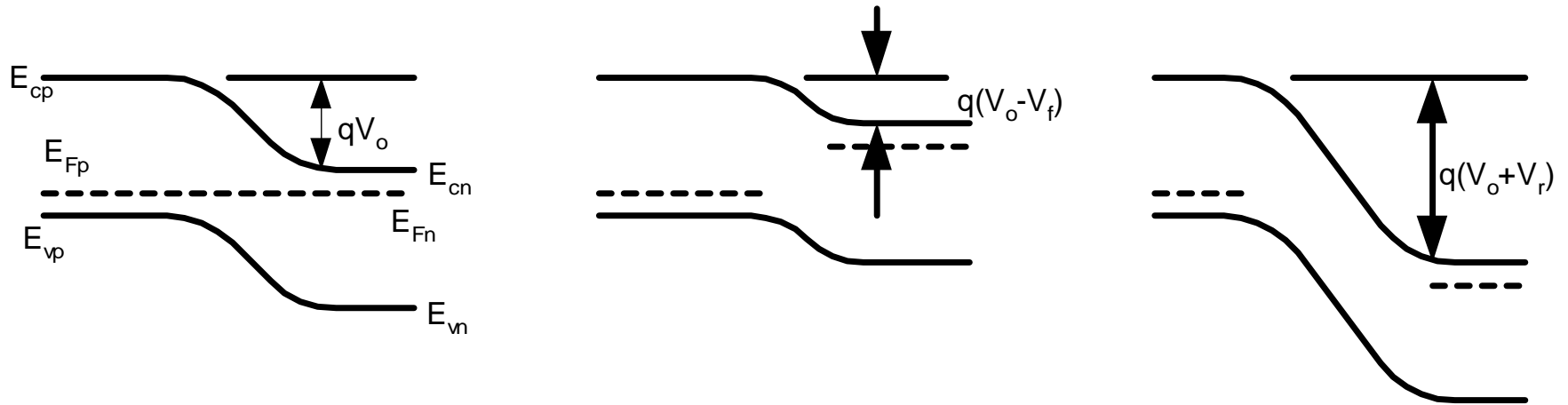
Applications

- List some Diode only Applications. Not diodes as part of a bjt or mosfet.

Equilibrium, forward bias, reverse bias



Equilibrium, forward bias, reverse bias



Equilibrium, forward bias, reverse bias

- Equilibrium
 - The Hole and electron drift and diffusion currents cancel each other out. No net current.
- Forward bias
 - The junction potential is lowered by an applied electric field.
- Reverse bias
 - The junction potential is increased by an applied electric field.

Equilibrium, forward bias, reverse bias

- Equilibrium
 - W does not change.
- Forward bias
 - W is smaller substitute $(V_o - V)$ for V_o in equation for W .
- Reverse bias
 - W is larger substitute $(V_o + V)$ for V_o in equation for W .

Equilibrium, forward bias, reverse bias

- Equilibrium
 - $E_{Fp} = E_{Fn}$ flat throughout .
- Forward bias
 - $E_{Fp}(J)$ and $E_{Fn}(J)$ are separated by $q(V_f)(J)$.
- Reverse bias
 - $E_{Fp}(J)$ and $E_{Fn}(J)$ are separated by $q(V_r)(J)$.

Equilibrium, forward bias, reverse bias

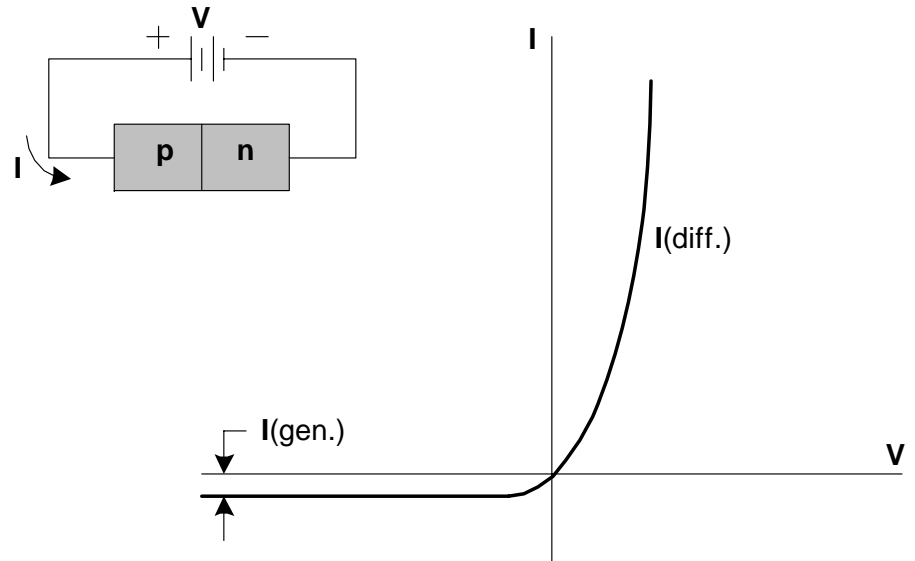
- Equilibrium
 - No net current .
- Forward bias
 - Diffusion current is increased because the barrier is lowered and thus more electrons and hole have enough energy to make it through the barrier. Electrons go from the n-side to the p-side. Holes go from the p-side to the n-side.
 - Drift current: small because this depends on the concentration of minority carriers. Thermally generated EHP's (within a diffusion length of W , are the only carriers that contribute to drift, thus independent of applied bias.

Equilibrium, forward bias, reverse bias

- Reverse bias
 - Diffusion current is decreased because the barrier is higher and thus less electrons and hole have enough energy to make it through the barrier. Electrons go from the n-side to the p-side. Holes go from the p-side to the n-side.
 - Drift current: small because this depends on the concentration of minority carriers. Thermal generated EHP's (within a diffusion length of W , are the only carriers that contribute to drift, thus independent of applied bias.

Equilibrium, forward bias, reverse bias

- Equilibrium: $I = I(\text{Diff}) - |I(\text{gen})| = 0$
- Forward bias: $I = I_o(e^{qV/kT} - 1)$
- Reverse bias: $I = I_o$



Carrier injection

- Minority carriers dominate

$$I = qA \left(\frac{D_p}{L_p} p_n + \frac{D_n}{L_n} n_p \right) (e^{qV/kT} - 1)$$

$$D_p = \frac{kT}{q} \mu_p, \quad L_p = \sqrt{D_p \tau_p}$$

$$p_n = \frac{p_p}{e^{qV_o/kT}} = \frac{N_a}{ni^2}$$

$$D_n = \frac{kT}{q} \mu_n, \quad L_n = \sqrt{D_n \tau_n}$$

$$n_p = \frac{n_n}{e^{qV_o/kT}} = \frac{N_d}{ni^2}$$

Calculating junction current

- The mobilities are for electrons in p-type material, and holes in n-type material.

From figure 3-23 on page 99:

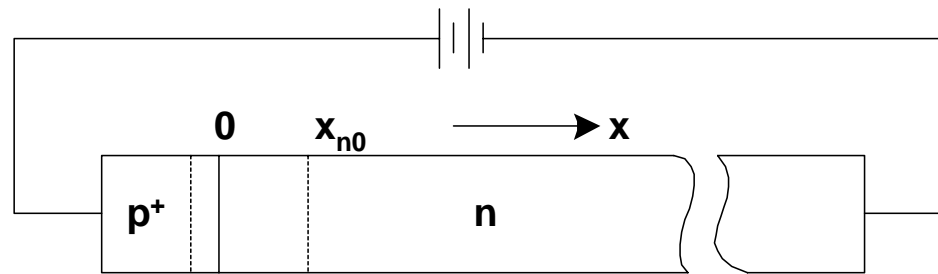
- An electron in p-type Si material ($N_a=10^{17}\text{cm}^{-3}$) would have a mobility of $1000\text{ cm}^2/\text{V s}$
- A hole in n-type Ge material ($N_d=10^{19}\text{cm}^{-3}$) would have a mobility of around $100\text{ cm}^2/\text{V s}$

Calculating junction current

- Minority carrier lifetimes:

	τ_n	τ_p
Si	10×10^{-6} s	10×10^{-6} s
Ge	10×10^{-7} s	10×10^{-7} s
GaAs	1×10^{-9} s	1×10^{-9} s
ZnSe	1×10^{-9} s	1×10^{-9} s

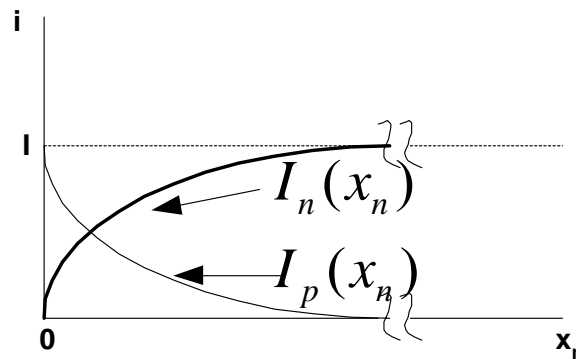
Minority and majority currents



→ I

$$I_p(x_n) = \frac{qAD_p}{L_p} \Delta p_n e^{-x_n/L_p}$$

$$I_n(x_n) = I - I_p(x_n)$$



Numerical Example

- Continue with ZnSe Example, Calculate I_{gen} .

$$\mu_{nZnSe} = 100 \text{ cm}^2 / \text{Vs}$$

$$\mu_{pZnSe} = 16 \text{ cm}^2 / \text{Vs}$$

$$\tau_n = \tau_p = 1 \times 10^{-9} \text{ s}$$